

Sir:

PATENT APPLICATION Docket No. 11675.163.2

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re application of:		)
	Terry N. Williams	)
Serial No.:	09/761,375	) Art Unit
Filed:	January 16, 2001	) 2882
For:	BUFFERED RESIST PROFILE ETCH OF A FIELD EMISSION DEVICE STRUCTURE	) ) )
Examiner:	Jurie Yun	) TECH <sup>y</sup>
Confirmation No.:	5328	RECEIV DEC 20 TECHNOLOGY CE
	AMENDMENT AND RESPONSE	EIVED 20 2002 Y CEKTER
Commissioner for Patents Washington, D. C. 20231		2800

In response to the Office Action mailed from the United States Patent and Trademark Office on August 2, 2002, please enter the following amendments and remarks into the file of the aboveidentified application.